Docket No.: DLED.004CP1C1

JUN 1 7 2004 Spplicant

INFORMATION DISCLOSURE STATEMENT

pplicant : Shveykin, Vasily I.

App. No. : 10/689,544

Filed : October 20, 2003

For : INJECTION LASER

Examiner : Unknown

Group Art Unit : 2812

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir:

Enclosed is form PTO-1449 listing one hundred eighteen (118) references. One hundred seventeen (117) of these cited references are of record in U.S. patent application No. 09/781,017, filed February 9, 2001, which is the parent of this Continuation application, and is relied upon for an earlier filing date under 35 U.S.C. § 120. Copies of these 117 references are not submitted pursuant to 37 C.F.R. § 1.98(d).

Applicant directs the Examiner's attention to U.S. Patent 6,649,938 entitled "Semiconductor Optical Amplifier", issued to Bogatov et al on November 18, 2003. A copy of this patent is also enclosed. U.S. Patent 6,649,938 corresponds to U.S. Patent Application No. 09/658,642.

The references EP 0247 267 B1 and SU 1329533 A1 are cited in the international search report for the International Application No. PCT/RU99/00067 entitled "Semi-Conductor Optical Amplifier" (see International Publication No. WO 99/46838) to which U.S. Patent Application No. 09/658,642 and thus U.S. Patent 6,649,938 claims priority.

Applicant is also citing JP 60-211993. This reference was cited by the Examiner in U.S. Patent Application 09/658,642 entitled "Semiconductor Optical Amplifier" corresponding to U.S. Patent 6,649,938.

The two references EP 0849812 and SU 1455373 are cited in the international search report for the International Application No. PCT/RU99/0245 entitled "Injection Non-Coherent

Appl. No.

10/689,544

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October 20, 2003

Docket No. DLED.004CP1C1 Customer No. 20,995

Emitter" (see International Publication No. WO 00/39860), to which U.S. Patent No. 6,429,462

issued to Shveykin and entitled "Injection Incoherent Emitter," claims priority. Applicant has

also cited U.S. Patent No. 6,429,462 issued to Shveykin et al.

Non-patent reference no. 39, "Optoelektronika [Optoelectronics]", Yu. R. Nosov, Radio i

svyaz, [Radio and Communications], Moscow, Publ. (1989), pp. 136-143, is cited in U.S. Patent

No. 6,429,462 issued to Shveykin and entitled "Injection Incoherent Emitter," at column 6, line

29-34.

Applicant is citing WIPO Publication WO 99/08352 (in Russian) which includes an

abstract in English. Applicant is also citing Russian Patent RU 2,133,534. A translation of the

abstract for this patent was obtained from the Delphion database (www.delphion.com) and was

submitted U.S. patent application No. 09/781,017, filed February 9, 2001, which is the parent of

this Continuation application, and is relied upon for an earlier filing date under 35 U.S.C. § 120.

Applicant is additionally citing two Russian language articles from *Quantum Electronics*

(non-patent references Nos. 104 and 105). Applicant does not have translations of the two

articles; however, the articles end with brief English language abstracts.

This Information Disclosure Statement is being filed before the receipt of a first Office

Action on the merits, and presumably no fee is required in accordance with 37 C.F.R.

§ 1.97(b)(3). If a first Office Action on the merits was mailed before the mailing date of this

Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to

Deposit Account No. 11-1410.

6/14/04

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated:

Mark J. Qallagher

Registration No. 43,622

Attorney of Record

Customer No. 20,995

(949) 760-0404

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FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

ATTY. DOCKET NO. DLED.004CP1C1 APPLICANT Vasily I. Shveykin FILING DATE October 20, 2003

APPLICATION NO. 10/689,544

GROUP 2812

U.S. PATENT DOCUMENTS

EXAMINER		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE
INITIAL							(IF APPROPRIATE
	1	4,063,189	12/13/77	Scifres et al.			
	2	5,101,413	3/31/92	Botez		•	
	3	5,537,433	7/16/96	Watanabe			
	4	5,705,834	1/1998	Egalon et al.			
	5	5,779,924	7/1998	Krames et al.			
•	6	5,793,062	8/1998	Kish, Jr. et al.			
	7	5,818,860	10/1998	Garbuzov			
•	8	6,057,562	5/2000	Lee et al.			
	9	6,429,462	8/2002	Shveykin			
	10	6,649,938	11/2003	Bogatov et al.			

	FOREIGN PATENT DOCUMENTS							
EXAMINER DOCUMENT NUMBER D.		DATE	COUNTRY		SUBCLASS	TRANSLATION		
INITIAL							YES	МО
	11	SU 1329533 A1	05/1998	Soviet Union			Х	
	12	SU 1359833 A1	15/12/87	Soviet Union			Χ	
	13	1,455,373	30/01/89	Soviet Union				· · ·
	14	2,133,534	7/20/99	Russia				
	15	2,134,007	07/27/99	Russia			Х	
	16	2,142,661	12/10/99	Russia .			Χ	
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	18	EP 0 247 267 B1	10/1991	Europe				
	19	EP 0727827 A3	21/08/96	Europe				
	20	EP 0849812 A3	24/06/98	Europe				
	21	60-211993	10/1985	Japan				
	22	WO 85/03809 A1	29/08/85	WIPO				
	23	WO 99/46838	09/1999	WIPO			Х	
	24	WO 99/08352 ,	02/1999	WIPO				

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INFORMATION (DISCLOSURE STATEMENT		
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	FOREIGN PATENT DOCUMENTS							
EXAMINER		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANS	LATION
INITIAL							YES	NO .
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	EXAMINER	DATE CONSIDERED
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FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. DLED.004CP1C1	APPLICATION NO. 10/689,544
INFORMATION DISCLOSURE STATEMENT BY APPLICANT			
		APPLICANT Vasily I. Shveykin	

GROUP 2812

FILING DATE October 20, 2003

(USE SEVERAL SHEETS IF NECESSARY)

EXAMINER INITIAL		OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)
	45	High-power, high-efficiency 1.3 μm superluminescent diodes with a buried bent absorbing guide structure, Haruo Nagai et al., Applied Physics Letters, Volume 54, Number 18, May 1989, pp. 1719-1721.
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	49	980-nm Master Oscillator Power Amplifiers with Nonabsorbing Mirrors, R. M. Lammert et al., IEEE Photonics Technology Letters, Vol. 11, No. 9, September 1999, pp. 1099-1101.
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EXAMINER	DATE CONSIDERED
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS	S IN CONFORMANCE WITH MPED 600: DRAW LINE THROUGH CITATION IS NOT

FORM PTO-1449 U.S. DEPARTMENT OF COMMERC PATENT AND TRADEMARK OFFICE		APPLICATION NO. 10/689,544	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT	APPLICANT Vasily I. Shveykin		.
(USE SEVERAL SHEETS IF NECESSARY)	FILING DATE	GROUP	

EXAMINER INITIAL		OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)
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EXAMINER	DATE CONSIDERED
*EXAMINER: INITIAL IE CITATION CONSIDERED, WHETHER OR NOT CITATION I	S IN CONFORMANCE WITH MPEP 609: DRAW LINE THROUGH CITATION IF NOT

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APPLICANT Vasily I. Shveykin

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	DISCLOSURE STATEMENT APPLICANT	APPLICANT Vasily I. Shveykin	
(USE SEVERAL	. SHEETS IF NECESSARY)	FILING DATE October 20, 2003	GROUP 2812

EXAMINER INITIAL		OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)			
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